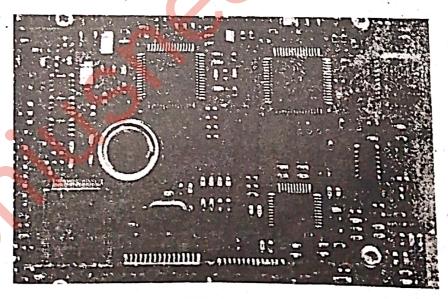
## **Unit** -17

# ELECTRONICS

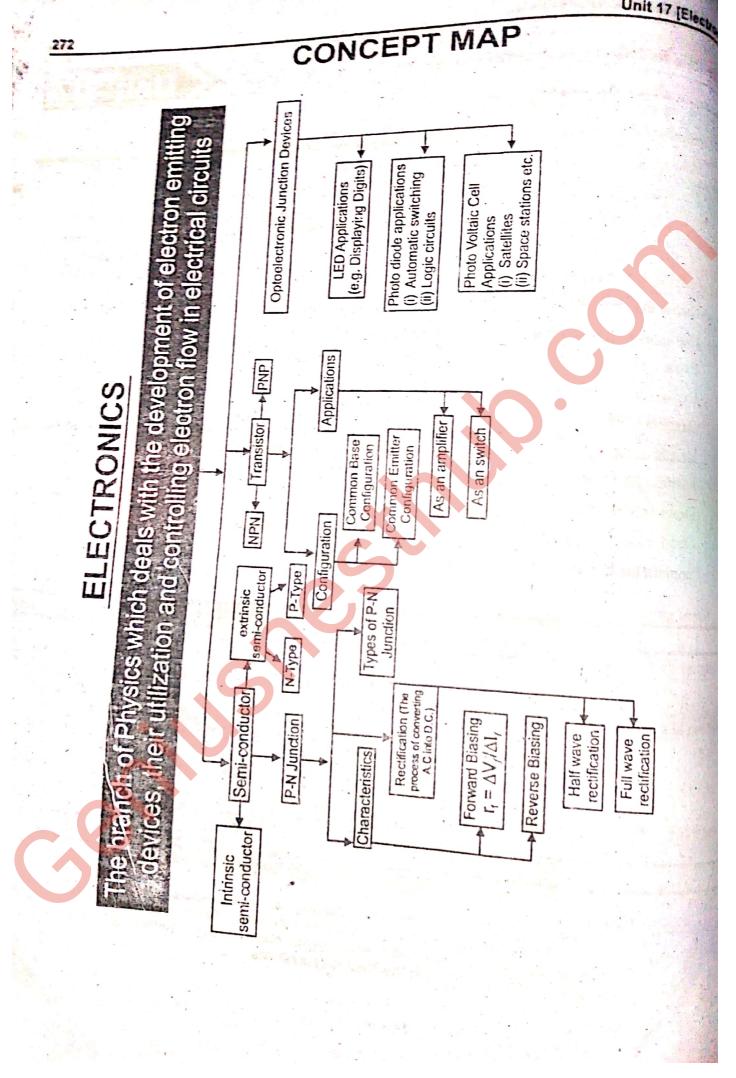
## Learning Objectives

## After studying this chapter the students will be able to:

- Distinguish between intrinsic and extrinsic semiconductors.
- Distinguish between P & N type substances.
- Explain the concept of holes and electronics in semiconductors.
- Explain how electrons and holes flow across a junction.
- Describe a PN junction and discuss its forward and reverse biasing.
- Define rectification and describe the use of diodes for half and full wave rectifications.
- Distinguish PNP & NPN transistors.
- Describe the operations of transistors.
- Deduce current equation and apply it to solve problems on transistors.
- \* Explain the use of transistors as a switch and an amplifier.



Semiconductors are materials having an intermediate electric conductivity between conductors and insulators. Semiconductors are essential to the good functioning of many modern appliances and are key products in the electronic systems.



Transistor is the basis of the integrated circuits that run our computers and many modern technologies, including programmable controllers. Many modern technologies use electro-mechanical principles to interface real world sensors and outputs to microprocessors, temperature controllers.

This unit increases students' understanding of the applications and uses of physics.

## Semi conductor:

Solids whose conductivity is intermediate between conductors and insulators either due to temperature effect or due to addition of impurity are called semi -conductors.

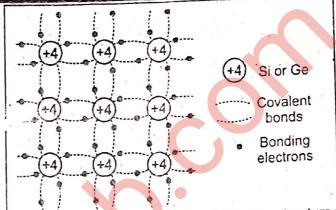
Differentiate between intrinsic and extrinsic semiconductor.

### Intrinsic Semiconductor

A semiconductor in its extremely pure form is called an intrinsic semiconductor.

A semiconductor is considered to be pure when there is less than one impurity atom in a billion host atoms.

- In a silicon crystal at absolute zero temperature the bonding arrangements may be represented by a two dimensional model as shown.
- ▶ In reality the semi- conductor is a three dimensional solid and the sharing of valance electrons occurs between nearest neighbor atoms in three dimensions.
- At zero Kelvin all valance electrons are strongly bound to their atoms and they spend most of the times between neighboring atoms.

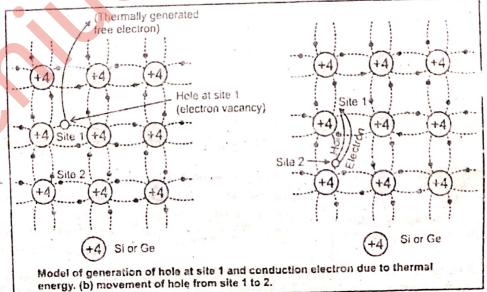


Two dimensional representation of Si or Ge structure. +4 symbols indicate inner cores of Si or Ge.

- Since all the valance electrons are engaged in covalent bonds, the bonds are complete.
- There will be no free electrons in such solids
- So semi-conductor at zero Kelvin does not conduct and behave as perfect insulator.

### Intrinsic semiconductors at room temperature:

- At higher temperature, the thermal energy causes each atom in the crystal to vibrate about its mean position. When the vibration become violent, some of the electrons acquire sufficient energy and break away covalent bond. The electrons liberated from bonds become free electrons which vibrate more randomly in the empty spaces that exist in the atoms at fixed positions.
- It means some of the electrons convert part of their thermal energy into potential energy. If this potential energy is equal to or more than the band gap energy, electron will be excited from valance band to conduction band
- The number of electrons excited to the conduction band depends on the amount of thermal energy received by the crystal,



When a covalent bond breaks in valance band and electron jumps to conduction band then a vacancy is created When a covalent bond breaks in valance band and electron in the conduction band can be excited to upper in the valance band. The electron in the valance band and electron in the crustal as in the valance band. The electron in the valance band and electron in the crystal at ordinary vacant level with in respective bands. If an electric field is applied current flows in the crystal at ordinary temperature.

#### Energy band gap:

It is the minimum amount of energy required to excite an electron from valance band to conduction band. It is characteristic of a particular material.

#### Note:

The motion of valance electron in the valance band is customarily described in term of fictitious particle called hole which has positive charge +e and its mass is equal to the mass of electron.

#### Intrinsic carriers:

Inpure semiconductors, a single event of bond breaking leads to two carriers, namely an electron and a hole. The electron and hole are created as a pair and the phenomenon is called electron-hole pair generation. The thermal generation is one possible mechanism for pair generation.

At any temperature T, the number of electrons generated will be therefore equal to the number of holes generated If N denotes the number density of electrons in the conduction band and P the number density of holes in the valence band, then,

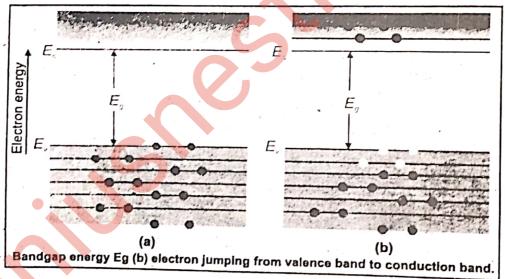
$$N = P = N_i$$

Where,  $N_i$  is called the intrinsic density of intrinsic concentration.

After the generation, the carriers move independently,. The electron moves in the conduction band and the holes moves in the valence bond. .

We can also define a semiconductor as intrinsic semiconductor in which free electrons and holes are created only by excitation of electrons from the valence band to the conduction band.

The energy band structure of a semiconductor is characterized by a valence band and a conduction band separated by the band gap  $E_z$  as shown in the fig 17.3:



The electrons completely occupy the valence band leaving the conduction band vacant. As a 1 the states in the valence band. Electrons in the valence band do not possess enough energy to jump into the conduction band. Therefore, an externally applied electric field cannot cause a flow of current and the semiconductor nearly at 0" ochaves as an

### Doping of Impurities

### Doping of Impurities:

The intrinsic semiconductors have low conductivity which is of little interest. But, when a small amount of impurity is added to semiconductor crystal then it greatly increases the conductivity of the intrinsic semiconductor.

An addition of impurity into an intrinsic semiconductor is called doping. The impurity added is called a dopant. Pentavalent elements from Group V or trivalent elements from group III are used as dopants. The atoms belonging to

these two groups are nearly of the same size as silicon or germanium atoms and easily substitute themselves in place of some of the host atoms in the semiconductor crystal. Thus, they are substitution impurities and do not cause any distortion in the original crystal structure.

## Extrinsic semiconductor:

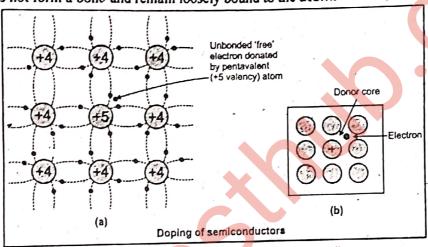
A semiconductor doped with a impurity atoms is called an extrinsic semiconductor.

Two types of extrinsic semiconductors, namely N- type and P-type semiconductors are produced depending upon the group of impurity atom.

Differentiate between N-type and P-type extrinsic semiconductor.

## N.Type Semiconductor

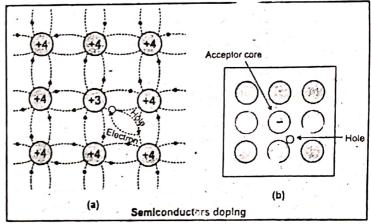
- An N-type semiconductor is produces when a pure semiconductor is doped with a pentavalent impurity.
- Phosphorous, antimony and arsenic are the dopants normally used.
- Suppose a phosphorous atom is doped with a silicon atom in the crystal. Phosphorous atom has five valence electrons. Out of the five electrons, only four can participate in the bonding, since these are only four bonds are shown in the fig the fifth electron does not form a bond and remain loosely bound to the atom.



- ▶ The impurity atoms which contribute electrons to the conduction band are called donor atoms.
  - They produce electrons without producing holes in the valence band.
  - At very low temperature, the donor atoms are not ionized and the conduction band is empty.
  - At slightly increased temperatures, the donor electrons populate the conduction band.
  - At ordinary temperatures, some electrons from the valence band are also excited into the conduction band through the intrinsic process.
  - The holes in the valence band are smaller at ordinary temperatures.
- The electrons which are in majority are called majority carriers whereas the holes are called minority carriers, since they are very small in number.
- As the current is mainly carried by electrons which are negative charge carriers, the semiconductor is called an Ntype extrinsic semiconductor, where N indicates the negative sign of the majority carrier.
- The net charge of N-type extrinsic semiconductor is zero.

#### P-Type Semiconductor

- The semiconductor which is formed by adding trivalent impurity to a pure semiconductor is called P-type semiconductor.
- An atom belonging to third group (Trivalent) such as aluminium (Al), boron (B), gallium (Ga) or Indium has three valance electrons.
- When a trivalent impurity atom is added with a silicon atom, it falls short of one electron for completing the four covalent bonds with its neighbors as shown.



- The substitution of a host silicon atom with, say, a boron atom does not disturb the neutral environment around the boron atom. However, when an electron from a neighboring atom acquires energy and jumps to form a bond, it leaves behind a hole.
  - The boron atom having acquired an additional electron becomes a negative ion.
  - The hole can move freely in the valence band whereas the impurity ion is immobile.
  - The impurity atoms which accept electrons from the valence band are known as acceptor atoms.

    The acceptor impurity atoms which accept electrons from the valence band are known of the electrons.
  - The acceptor impurity atoms produce holes without the simultaneous generation of the electrons, in the
  - At ordinary temperatures, holes are produced due to intrinsic process also, by promoting electrons from valence

  - The result is that no of holes becomes greater than no of electrons in the semiconductor.

    Therefore has Therefore, holes are the majority carriers and electrons are minority carriers in this type of semiconductor.

    As positively the As positively charged carriers are mainly contributing to the conduction process, this type of semiconductor is known as a P-type available of the region of

  - known as a P-type extrinsic semiconductor where P signifies positive sign of the regionity carriers.

    The net charge of P

## What is P-n Junction? Discuss Forward blas and reverse blas PN-Junction their Characteristics Q.3

### in Detail?

If the crystal of germanium or silicon is grown in such a way that PN Junction it's one half is doped with trivalent imparity and the other half is doped with pentavalent impurity, p-n junction is formed.

#### Explanation:

- At the junction, electrons from N-type fill the vacancies in P-region; thus negative and positive ions are formed.
- These ions create an electric field directed from N- to P- type region.
- It stops further diffusion of electrons and holes and maintains the separation of charge carriers.
- The junction region is now free of mobile charges and it is called depletion region or layer.
- The width of depletion layer depends upon carrier concentration. Thus a notential wall or barrier is formed at the junction.
- The symbol of PN junction (diode) is shown in fig.

## Forward biased PN junction:

When P-type region is connected with positive potential with respect to N-type region and the potential drop is increased slowly, the junction barrier height decreases.

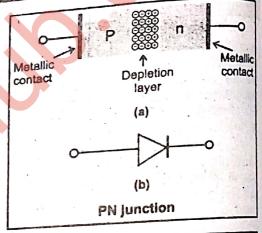
At one point, called as knee voltage, majority charge carriers cross the junction and the current flows, as shown in fig. this is called forward bias and the current is called forward current.

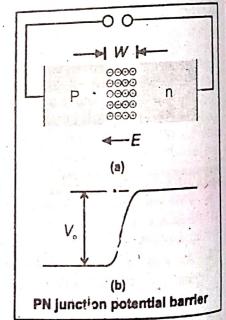
### Reverse biased PN junction:

If P-type region is made negative with respect to N-type, no majority charge carries cross the junction and hence there is no current

A small amount of current flows due to minority charge carriers, this biasing is called the reverse bias and the current is called as reverse current.

The reverse current is generally of the order of few microamperes.

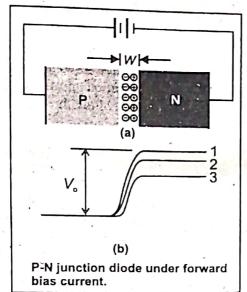


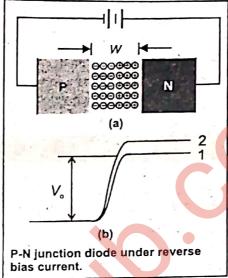


### VI Characteristics of PN Junction

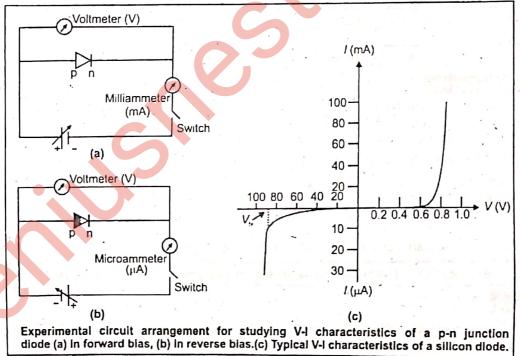
### Knee voltage:

The forward voltage at which the current through the PN junction starts increasing rapidly is known as knee voltage. It is also called as cut-in -voltage or threshold voltage.





The VI characteristics of PN junction are shown in fig. The knee voltage is 0.3V for germanium and 0.7V for silicon. From the VI characteristics, we see that the forward current increases rapidly beyond the knee voltage. There exists a maximum current limit for junction, which is decided by the power ratio of the junction. Beyond that, the junction is destroyed.



#### Reverse saturation current:

For a diode in revere bias diode the current is very small ( $\mu$ A) and is called reverse saturation current. It flows due to minority carriers. It increases with a increase in temperature.

#### Zener effect:

In reverse bias, if voltage is increased, due to available energy, covalent bonds break and large number of electrons are released. This cause a sudden increase in current. This is called as zener effect.

If reverse bias is increased further, minority charge carriers attain high velocity and knock down the bound in reverse dias is increased runner, minority charge carriers attain and these effects, zener electrons from covalent bonds and the current increases. This is called as avalanche effect. Using these effects, zener

### Differentiate between Zener Breakdown and Avalanche Breakdown: diodes are formed.

When the diode is reverse biased, the kinetic energy of the electrons increases and they move at a high velocity. The high-velocity electrons collide with other atoms and give rise to free electrons. These free electrons, in turn, give rise to a high value of reverse saturation current. This is known as zener breakdown. The avalanche breakdown occurs when a high reverse voltage is applied across the diode. As we increase the applied reverse voltage, the electric field across the junction increases. This electric field exerts a force on the electrons at the junction and frees them from covalent bonds. These free electrons start moving with high velocity across the junction and collide the other atoms creating more free This results in the rapid increase of net current. Both these breakdowns occur in Zener diodes.

electrons. This results in the rapid increase of net current. Both	Avalanche Breakdown
Zener Breakdown	of applying high voltage and
• The process in which the electrons move across the barrier from the valence band of p-type material to the conduction band of n-type material is known as zener breakdown.	increasing the free electrons of electrons in called
This is observed in zener diodes having a zener	breakdown voltage Vz greater than 8 volts.
breakdown voltage Vz of 5 to 8 volts.	lectrons are pushed to conduction due
• The valence cons are pulled into conduction due to the high tric field in the narrow depletion region.	which gains its velocity due to its collision with other atoms.
	• The increase in temperature increases the
The increase in temperature decreases the breakdown	breakdown voltage.
The VI characteristics of a zener breakdown has a	• The VI characteristic curve of the avalanche breakdown is 10. as sharp as the zener breakdown.
sharp curve.	It occurs in diodes that are lightly doped.
It occurs in diodes that are highly doped.	

### **Drift of Minority Carrier**

It is seen that the electric field across the junction prevents the diffusion of majority carriers. However, the electric field has the right direction to promote the flow of minority carriers across the junction. Electrons arriving at the junction from the bulk of P-region are assisted by the electric field to move into N-region. Similarly, holes in the N-region are helped to move into P-region. As a consequence, an electric current flows across the junction.

As the current is caused by an electric field it is a drift current. The net drift current through the junction is due to electron and hole which is given by.

$$I_{(drift)} = I_c + I_h$$

The minority carriers are generated through breaking of covalent bonds.

#### What is rectification? Discuss the Working of Different types of Rectifier Circuits? Q.5

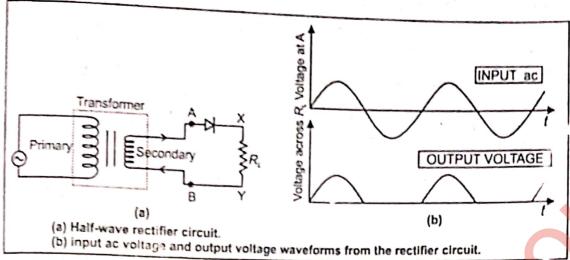
#### Rectification

Some electronic devices like electronically tune radio and TV receivers require DC for their operation. The DC supplies like cells, batteries etc. are expensive, low power, and short-lived. Therefore generally a DC supply is generated using an A.C. supply.

The conversion of AC into DC is called the rectification and a device used for rectification is called the rectifier.

Diodes provide compact, inexpensive means of rectification therefore it can be used as a rectifier. As we have seen, when diode is forward biased it allows the current to pass and in reverse bas it (almost) stops the current. Thus it can be used as unidirectional device (or rectifier). For most power applications, half-wave rectification is insufficient for task.

If we need to rectify AC power to obtain full use of both half-cycles of sine wave, different rectifier circuit configuration must be used. Such circuit is called full-wave rectifier.



The circuit which converts half of the alternating current cycle into direct current is called as half wave rectifier circuit.

A half wave rectifier circuit is shown in figure. This circuit uses a transformer to couple the A.C input voltage from the source to the rectifier because it can step up or step down the source voltage when needed and also because A.C source is electrically isolated from the rectifier thus preventing a shock hazard in the secondary circuit. The voltage across the secondary of transformer is represented as

$$V = V_{\pi} \sin \omega t$$

Where  $V_{\pi}$  is the peak value of alternating voltage.

<u>During the positive half cycle</u>  $(0 \longrightarrow T/2)$ , of the input A.C signal, the diode is forward biased. So it offers low resistance and current flows through it

During the negative half cycle  $(T/2 \longrightarrow T)$ , of the input A.C signal, the diode is reverse biased. So it offers very high resistance and no current flow through R.

The same process continues for next half cycles and so on for an a. c input. However the current flows in one direction, so it is direct current, which has pulses. The final output is called pulsating D.C.

During negative half of input A.C cycle peak inverse voltage (PIV) is the maximum voltage  $V_m$  that the rectifying diodes have to withstand. Thus the maximum voltage that appears across the diode is equal to the peak voltage  $V_{max}$ . Hence for half wave rectifier,

$$PIV = V_{max}$$

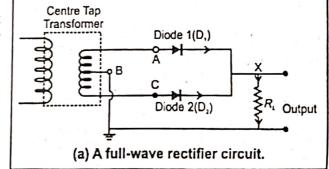
#### Full-wave rectifier

The circuit which converts both the half cycles of input A.C signal in to the D.C signal is called full-wave rectifier circuit.

#### Explanation:

A full wave rectifier circuit having a transformer with center-tapped secondary winding and two diodes in alternate switching mode is shown in fig.

A full wave rectifier allows unidirectional (one way) current through the load during the entire cycle of the input cycle,



whereas a half wave rectifier allows current through the load during one half of the cycle. The diodes D<sub>1</sub> and D<sub>2</sub> operate in alternate switching mode.

#### For the first half of input A,C cycle:

For the first half cycle point, A becomes positive with respect to B and B becomes positive with respect to C. thus, D<sub>1</sub> is forward and D<sub>2</sub> is reverse biased. The current through load is only due to D<sub>1</sub> while current due to D<sub>2</sub> is zero. For the second half of input A.C cycle:

For the second half cycle, point C becomes positive with respects to B and B becomes positive with respect to A.

280

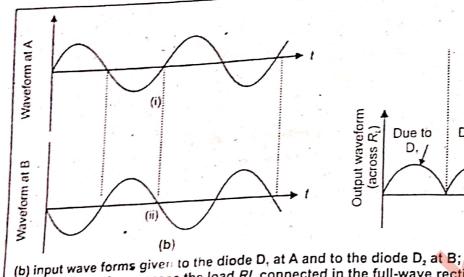
Now D<sub>2</sub> is forward biased ON and D<sub>1</sub> is reverse biased OFF. The current flows due to D<sub>2</sub>. Now D<sub>2</sub> is forward biased ON and D<sub>1</sub> is reverse biased OF 1. Thus

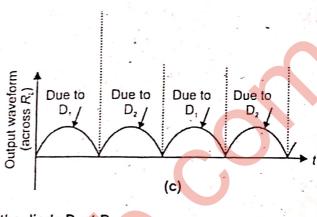
For the first half of the cycle, the current is due to D<sub>1</sub> and for the second half cycle, the current is due to D<sub>2</sub>. Thus full wave is rectified.

#### Disadvantage:

sadvantage:

One disadvantage of this full-wave rectifier design is necessity of transformer with center-tapped secondary winding





- (c) Output waveform across the load RL connected in the full-wave rectifier circuit.

## MCQ's From Past Board Papers

At 0K semi conductors are (C) Perfect conductors (B) Insulators (D) Perfect insulators (A) Conductors In forward biasing, the value of resistance is (C) Small (B) Very large (D) Very small (A) Large For rectification we use (B) Diode (C) Choke (A) Transformer (D) Generator Reverse current flows due to (A) Majority charge carriers (B) Minority charge carriers (C) Electrons (D) Holes The photodiodes are used for: (A) Security system (B) Counting system (C) Automatic door system (D) All of above The potential barrier of Ge is (B) 0.7 V (A) 0.9 V (C) 0.5V (D) 0.3V is the electrical symbols for: (A) Diode (B) Photodiode (C) photocell (D) LED Conversion of A.C. into D.C. is called: (A) Modulation (B) Amplification (C) Oscillation (D) Rectification A potential barrier of 0.7 volt exist across p-n junction made from: (B) Germanium (C) Indium (A) Silicon (D) Gallium When a P-N junction is reverse biased, the depletion region is: (A) Wider (B) Narrow (C) Normal (D) No change Universal gate is the gate which can perform the function of: (B) any logic gate (A) buffer gate (O) any basic gate (D) any exclusive gate The number of terminal in a semiconductor diode are: (B)3(C)4(D) 5 A light emitting diode (LED) emits light only when: (A) Reverse biased (B) Forward biased (C) Unbiased (D) None of these Which factor does not affect the conductivity of PN-junction diode: (A) Doping (B) Temperature (C) Voltage (D) Pressure Light emitting diodes (LED) are made from semi-conductors: (A) Silicon (B) Germanium (C) Carbon (D) Gallium arsenide

Service Service	Pulsati	ng out pu	t of full w	ave rectifie	er can be	made sn	000	th by well	o olesuit	-111			1
	(A) Filt	DIF.		(B) Am	plifier	all	100	(C) De-	ig circuit d	alled;	The second	19 " PE	100 M (100 Mag)
	(A) Filter (C) Resistor specially designed p.n. junction used as indicator in electronic circuits is:									(D) Transi	stor	81	
	A) LET	)		(B) Sol	ar cell	ator iii e	HEC						
	when i	a silicon c	rystal is d	loped with	a pentav	alent ala	me	nt it bass	to voltaic co	ell	(D) Photo	diode	,
	(A) Out	pe semico	nductor	(B) n-tv	pe semico	andustor	me						
	(A) P G	inction ca	in not be i	used as:	rpe semico	muuctor		(C) Intri	nsic semico	inductor	(D) only s	emiconduct	or
	(A) Rec	tifier		(B) Am	nlifier			(0) 0					
	(A) Not	e characte	eristic cur	ve is platt	od betwee			(C) Dete	ector		(D) LED	*	
	A diode characteristic curve is plotted between  (A) Current and time  (B) Voltage and time												
	(A) CUI	tern and r	urrant						age and tim				
	(C) Voltage and current (D) Forward voltage and reverse voltage The ratio of potential barriers of Ge to Si at room temperature is:												
	The rai	tio of pote	nuai barri			om tem	Peri						
	(A) 7:	3		(B) 1:				(C) 2:5	5		(D) 3:7		
	in full	wave brid	ge rectifie	r the num	ber of dio	des requ	uire	ed are equ	al to				
	(A) 3			(B) 4				(C) 5			(D) 1		1
	The co	lour of lig	nt emitted	by a LED	depends	on							7 11
	(A) its f	forward bia	ising								r material u	sed	
	(C) the	amount of	forward c	urrent				(D) its r	everse bias	sing			30 ' Luu
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		e charge			e charge			(C) lons	•		(D) No ch	narge	100
			iodes (LE	D) are mad		mi-cond	duct					h	
	(A) Sili				rmanium			(C) Car	bon		(D) Gallit	um arsenide	
				nt is direc	tly propor	tional to	):			4			
	sw (A)	velength o	flight	(B) into	ensity of lig	ght		(C) freq	uency of lig	ght	(D) energ	39	
	In p-ty	pe substa	nces, the	minority o	carries are	: '					7		
		ectrons		(B) Pro				(C) Hol	es		(D) Neut	rons	
			tration of	impurity is	added in	:							
	(A) Ba	se		(B) En	nitter			(C) Col	lector		(D) LED		
	Which	one can	be used a	s tempera	ture sense	or in elec	ctri	c circuit?					
	(A) Ca	pacitor		(B) Did	ode			(C) LDI	3	(D) Thermistor			
).	The b	arrier pote	ntial of S	ilicon Dioc		temper	atu	re is:					
	(A) 0.3			(B) 0.7				(C) 3 V			(D) 7 V		
			t flows du										
	(A) Ma	ajority char	ge carries	(B) Mi	nority char	ge carrie	ers	(C) ele	ctrons		(D) hole	S	
2.	Durin	g negative	half cycle	e of A.C th	enp-n	Junction	of						
•		gh resistar		(B) Lo	w resistan	ce		(C) No	resistance		(D) All c	of these	
1.	Then	uleating o	utnut volt	age of a re	ctifier car	n be mad	de s	smooth by	using a c	ircuit kno	wn as:		
			d inductor	(B) Inc	ductor			(C) Filt	er		(D) Res	istor	
4	A nho	spacific di	an turn ite	current O		Fin:		(3)					
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5.			as d into D.C		ga second			(0) 110	5000.74		(=)		
			u mto D.C	(B)ind	uctor			(C)tran	sistor		(D) dio	de	
6.		pacitor	neko at ea-	erse biasi		•		(U)tidi	313101		(5) 010		
			orks at rev		_	cell		(C) Dh	otodiode		(D) Sin	con diode	
7,	(A) LE		to	(B) Pr	otovoltaic	Cell		(C) Ph	otodiode		(0) 5111	con aloue	
,		odiode det	ects	(10) 4-4	and links			(0)	muintal ti-k		(D) all	of them	
8.		sible light			ra-red light	Ĭ.		(C) ulti	aviolet ligh	I	(U) all	of them	
٠.		,	used for d	etection of									
_	(A) H	eat		(B) Ma	agnet			(C) Cu	rrent		(D) Li	ght	- Fig. 1
						Ansv	Ner	s Key					
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1. B	2. D	3. B	4. B	5. D	6. D	7. D	8. D	9. A	10. A	11. C	12. A
	14. D	15. D	16. A	17. A	18. B	19. B	20. C	21. D	22. B	23. B	24. C
25. D	26. B	27. A	28. B	29. D	30. B	31. B	32. A	33. C	34. C	35. D	36. C
37. D	38 D	1			,				14		

### What is a Transistor? Discuss its Construction and Different Types?

## Transistor

A transistor consists of two back to back pn-junctions made in a signal piece of semi- conductor crystal. The word transistor is short form of transference of signal across a resistor.

#### Types of modern transistor:

Modern transistor are of two types.

- 1. Bipolar: whose function depends upon both (majority and minority) charge carriers. (BJT)
- 2. Unipolar: whose function depends upon majority charge carrier's i.e. field effect transistor. (FET)

#### Bipolar junction Transistor. (BJTs)

There are two BJTs transistors:

(1)p-n-p transistor

n-p-n transistor (2)

#### (1) p-n-p transistor:

When n-type substance (Si or Ge) is sandwiched between two p-type substances, then device formed is called. n-p transistor, Its electronic symbolic shown in figure with symbolic representation.

#### (2) n-p-n transistor:

When a p-type substance is sandwiched between two n-type substances, then device formed is called in transistor. Its electronic symbol is shown in figure

#### Parts (or-regions) of Transistor:

The main parts of transistor are:

(i) Emitter (ii) Base

(iii) Collector

#### (i) Emitter:

- The emitter has greater concentration of impurity atoms as compared to collector, so it has more charge carriers than collector.
- The arrow on emitter terminal shows the direction of conventional current. (Outward for NPN and inward for PNP)
- Emitter is smaller in size as compared to collector.

#### (ii) Base:

- The central region is known as base. Usually, the base is very thin of the order of 10<sup>-6</sup>m.
- It has least concentration of impurity as compared to emitter and collector.
- It controls the flow of electron from emitter to collector.

## Emitter Emitter Base Collector Base (a) Base Collector (b)

(a) N-P-N transistor and P-N-P transistor, and (b) Symbols for N-P-N and P-N-P transistors.

#### (iii) Collector:

- The collector collects majority charge carriers through base.
- The collector has less concentration of impurity as compared to emitter.
- The collector is comparatively larger in size than the emitter because it has to dissipate much heat energy.

#### Working of a Transistor:

- Emitter-base junction is forward biased by V<sub>IF</sub>
- ► While base-collector junction is reversed biased by V<sub>c</sub>.
- ► For normal operation V<sub>cc</sub> is greater than V<sub>IE</sub>
- After the application of the biasing voltage, emitter base junction is forward biased
- So emitter injects the large number of electrons in the base region.
- The electrons in the base can follow two paths
- They can either flow out of base to positive terminal of V<sub>IE</sub> or they can be attracted towards the collector due to V<sub>ec</sub>.
- ▶ Since the base is extremely thin, very few electrons manage to recombine with holes and escape out of the base
- The most all of free electrons injected from emitter into base are attracted into collector by large positive V<sub>cc</sub>.
- So an electronic current I<sub>E</sub> flow from emitter to base, a very small current of it I<sub>B</sub> flows out of the base and current

I flows out of the collector.

The direction of conventional current is opposite to the flow of electron.

Therefore current equation is

- In most cases NPN transistors are preferred because mobility of electrons is three times more than that of holes and therefore the operation is faster.

## 0.7 Discuss the different types of the Configurations of transistor.

## Types of configurations

One electrode is always common to both input and output in transistor circuits so there are three types of configuration of a transistor circuit.

## Common base configuration:

When a base is common to both input and output circuits, it is a common base configuration. Figure shows the circuit diagram and input and output characteristics of CB configuration.

#### Input characteristics:

The variation in the emitter current  $(I_E)$  with respect to change in the base- to-emitter voltage  $(V_{BE})$  at the constant collector-to-base voltage  $(V_{CB})$  is input characteristics.

#### Output characteristics:

The variation in the collector current  $(I_C)$  with change in the collector-to-base voltage  $(V_{CB})$  at the constant emitter current  $(I_E)$  is output characteristics. The output characteristics have three regions of operation, namely, active, cutoff and saturation.

#### Active region:

When the base-emitter junction is forward biased and the collector-base junction is reversing biased, it is active region.

#### Cutoff region:

When both, collector-base and back emitter junctions are reverse biased it is cutoff region. The output current is zero in this case.

#### Saturation region:

When both the junctions are forward biased, it is saturation region. Figure shows these regions.

#### Alpha factor:

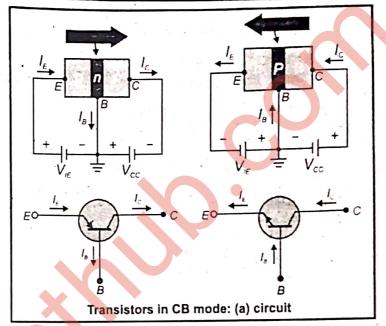
The ratio of  $I_C$  and  $I_E$  is called as alpha factor. It is an amplification factor.

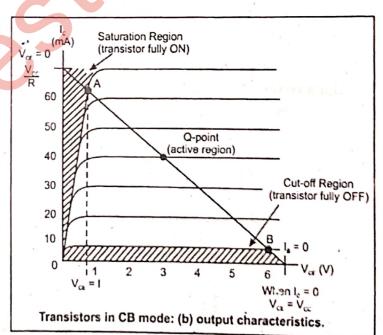
since  $I_C = I_E$ ,  $\alpha = 1$ . Therefore,

$$\alpha_{\rm static} = \frac{I_{\rm C}}{I_{\rm E}}$$

And

$$\alpha_{\rm dynamic} = \frac{\Delta I_{\rm c}}{\Delta I_{\rm E}}$$





In common emitter configuration:

The common emitter configuration is forward based while base-collector junction is reverse biased.

Fig shows circuit diagram, input and output characteristics, respectively.

The variation in base current (I<sub>B</sub>) with change in base-to-emitter voltage (V<sub>BE</sub>) at constant collector-to-emitter voltage (V<sub>BE</sub>) voltage (VCE) are input characteristics. Output characteristics:

Variation in collector current (I<sub>C</sub>) with change in collector-to-emitter voltage (V<sub>CE</sub>) at constant base current (I<sub>C</sub>) are output characteristics.

Fig shows active, cut-off and saturation region of output characteristics.

The ratio of collector current I<sub>C</sub> and base current I<sub>B</sub> is called as beta factor.

That is,

$$\beta_{\text{static}} = \frac{I_C}{I_H}$$

And

$$\beta_{\text{dynamic}} = \frac{\Delta I_{\text{C}}}{\Delta I_{B}}$$

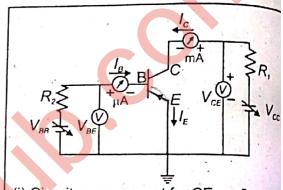
The beta factor is called as current gain or current amplification factor. Generally it ranges from 50 to 400. We can write,

$$\beta = \frac{I_C}{I_B}$$

$$\beta = \frac{I_C}{I_E - I_C}$$

$$\beta = \frac{I_C/I_E}{1 - I_C/I_E}$$

$$\beta = \frac{\alpha}{1 - \alpha}$$



(i) Circuit arrangement for CE configuration

Alpha factor: The ratio of Ic and IE is called as alpha factor. It is an amplification factor.

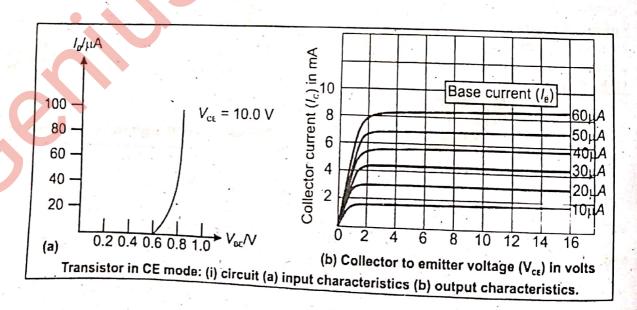
Since  $I_C \approx I_E$ ,  $\alpha \approx 1$ . Therefore,

$$\alpha_{\text{static}} = \frac{I_{\text{C}}}{I_{\text{E}}} \dots (17.3)$$

$$\Delta I_{\text{C}}$$

and

$$\alpha_{\text{dynamic}} = \frac{\Delta I_0}{\Delta I_1}$$



## How can we Use a Transistor as an Amplifier?

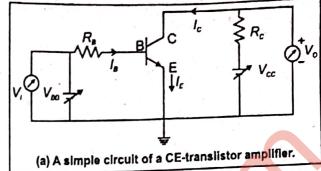
## Transistor as an amplifier Transistor as an amplifier:

A transistor can be characterized as a current amplifier.

It has many applications for amplification and switching.

The arrangement of common emitter amplifier is shown in fig.

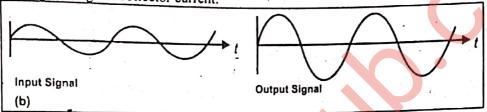
In above figure the input voltage appears across base and emitter, and the output voltage appears across the collector and emitter. I.e. the emitter terminal is shared by the input and output.



An increase in voltage or current level is called as amplifications. The transistor can be used as amplifier.

A small change in input (voltage or current) produces large change in output (voltage or current).

If β is 100 then the change in collector current is 100 times the change in base current. The small change in base current produces large change in collector current.



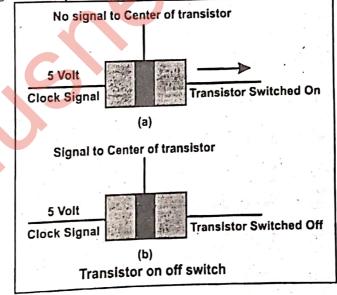
Thus transistor acts as an amplifier. The energy required for amplification is taken from the power supply. In most of the cases, CE mode is preferred because its current and voltage gains are high and power gain is the highest.

At the input, the emitter junction is forward biased therefore input resistance is small and the output, the collector junction is reverse biased therefore output resistance is high. The current is transferred from low-to-high resistance circuit.

#### How can we Use a Transistor as a Switch? Q.9

#### Transistor as a switch

Transistor is used in a great variety of circuits. Transistors switches form the basis of all electronic computers.



As

With the switch closed, base current flow causing collector to flow. The output voltage is V<sub>CE</sub>= 0 V fig. 17.18(a) the battery voltage is dropped across the load causing the collector voltage to fall to a very low value. The transistor is said to be saturated. With a switch open no base current flow, therefore no collector current can flow. The transistor is said to be cutoff.  $V_{CE} \approx + V$  (fig 17.18 (b)) these two states are described as 0 and 1, or low and high.

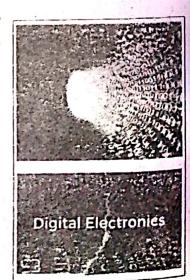
			AND DESCRIPTION OF	THE PERSON NAMED IN										
		Q's From	Past B	oard P	apera of:		(0	c) rec	tifier			(D)	oscillator .	
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	2.	(A) 10 m	in transist	or is called	) 10 111 d:			N Bloo	lear na	ain			Emitter ga	in
l	3. 4.	(A) Current ( For non-inv	gain erting amp	olifier if R	= oc ohm	$and R_2 = 0$	ohm, the	n ga () +1	in of a	mpl	ifier is	: (D)	Infinite	
	5.	(A) ⊷1 Transistors		from:	) Zero Metals				ductor		٠.	(D)	Dopped se	miconductors
	6.	(A) Plastics The term tra (A) Transfer		ands for:	Transfer	of voltage	(C	) Trai	nsfer of	f res	istance	(D)	Transfer of	charge
	7.	An expressi	on for curi	rent galn o	of the trans $\beta = l_B + l_C$	sistor is gi	ven by: (C	) β =	Ic — Iв			(D)	$3 = \frac{I_{C}}{I_{B}}$	
ı	В.	(A) $\beta = \frac{\ln}{\ln}$ The central	region of a	transisto	•		(C)	) Coll	ector			(D) !	Veutral	
	).	(A) Base Which one h (A) Emitter In a commor	as greater	concentra	ation of Im	npurity: difference b	(C) petween t	Colle the in	ector put sig	gna	voltag	(D) Vige and out	Whole transput signal	sistor I voltage is:
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1	1.	The commor	n emitter c	urrent amp	plification	factor β is	given by	:				- 1		
		$(A) \frac{I_B}{I_E}$		(B)			(C)	lc lE		V		(D) I	•	
1		The ratio $\beta$ tr (A) Current ga		101	√oltage ga	in .	(C)	Nucl	ear gai	n 100	iko la	(D) E	mitter gain	
	3.	The gain of n (A) 0.1	on inverti	(B)	10	nai resistat	(C)	11	2, 1,2 -		TAL IG	(D) -	10	
14		The gain of A $(A) = \beta R_C / r_{ie}$	Amplifier is		Br. / Rc		(C)	$-R_2$				(D) 1	+ R <sub>2</sub> R <sub>1</sub>	
5		The width of	central reg	ion of a tr. (B) 1	ansistor la 10 <sup>-6</sup> m	B: -	(C)	10-3	m			(D) 10	) <sup>-9</sup> m	
6	. ••••••••••••••••••••••••••••••••••••	of unit of curi		(B) v	olt		(c)	couló	mb			(D) no	unit	
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1. A	2. D	3. A	4. C	5. D	6. C	7. D	8. A	9. A	10. B	11. D	12. A
13. D	14. A	15. B	16. D	17. A	18. A	п - ,					
25. D	26. B	27. A	28. B	29. D	30. B						

#### Q.10 What is digital electronic?

#### Digital Electronics

- ▶ Digital calculators, watches, modern communication systems and computers are widely used in everyday life.
- All persons working in various fields related to electronics must understand the performance of Digital Electronics Circuits.
- ▶ All sizes of computers, as we know, perform complicated task with fantastic speed and accuracy.
- At stores, the cash register read out digital display.
- Digital clock and watches flash the time in all city shops and restaurants.
- ▶ Most automobiles use microprocessors to control engine functions.
- Aircraft's defense sectors, factory machines and modern diagnostic in medical science are controlled by digital circuits.



## Role of integrated circuits in digital electronics:

The inexpensive fabrication of integrated circuits (ICs) has made the subject digital electronics easy to study. One small IC can perform the task of thousands of Transistors Diodes and Resistors. Many ICs are used to construct Digital Circuits. This is an exciting and rapidly growing field, which uses several principles for the working of computers, communication systems, digital machinery's etc.

## Digital Systems and Digital Circuits:

Any device working under Digital Techniques are called Digital Systems and the Electronic Network used to make them operational is called Digital Circuits. The subject as a whole is often referred as Modern Digital Electronics.

Q.11 What are optoelectronic junction devices. Discuss the Different Types of Especially Designed p-n Junction Diodes?

## Optoelectronic junction devices

In semiconductor diodes carriers are generated by photons (photo-excitation). All such devices are called optoelectronic devices. Three commonly used such diodes are

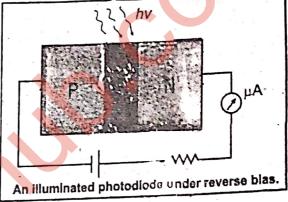
(i) Photodiodes

(ii) Light emitting diodes (LED)

(iii) Photovoltaic

(i) Photo Diode

A photodiode is a P-N junction diode, operated under reverse bias. When the photodiode is illuminated with light energy (hu) greater than the energy gap (Eg) of the semiconductor, then electron hole pairs are generated due to the absorption of photons. The diode is fabricated such that the generation of electrons holes pairs takes place in or near the depletion region of the diode. Due to electric field of the junction, electrons and holes are separated before they recombine. Electrons are collected on N-side and holes are collected on P-side giving rise to an



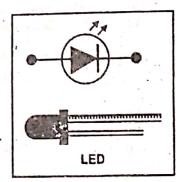
e.m.f. when an external load is connected, current flows. The magnitude of the photocurrent depends on the intensity of incident light (photo current is proportional to incident light intensity). Hence photodiode can be used for the detection of optical signals.

Uses:

- Detection-both visible and invisible lights.
- ▶ Logic circuits.
- Optical communication equipment.
- Security systems.
- ▶ Used in T-V to receive the signal of remote control.

(ii) Light emitting diode

It is a heavily doped P-N junction which under forward bias emits spontaneous radiation. When the diode is forward biased, electrons are sent from N -> P (where they are minority carriers) and holes are sent from p -> N (where they are minority carriers). At the junction boundary the concentration of the minority carriers increases compared to the equilibrium concentration (i.e., when there is no biasing). On either side of the junction, excess minority carriers are there which recombine with majority carriers near the junction. As a result energy is released in the form of photons. The diode is encapsulated with a transparent cover so that the emitted light can come out (diode converts electrical energy into light). LED's have fast action, long life and endurance and fast on-off 'switching capability. Special type of semi-conductors such as gallium arsenide and gallium arsenide phosphide are used in LEDs. The color of light depends upon the nature of the semiconductor.



Uses:

Remote controls,

Burglar alarm systems,

Optical communication

Display system

Used in traffic signal.

A solar cell is also a P-N junction which generates e.m.f. when solar radiation falls on the P-N junction. It works

A solar cell is also a P-N junction which generates e.m.f. when solar radiation falls on the P-N junction. It works A solar cell is also a P-N junction which generates child. When the same principle (photovoltaic effect) as the photodiode, except that no external bias is applied and the junction area on the same principle (photovoltaic effect) as the photodiode, except that no external bias is applied and the junction area on the same principle (photovoltaic effect) as the photodiode, except that no external bias is applied and the junction area. on the same principle (photovoltaic effect) as the photographic, except that the generation of emf by a solar cell, When light is kept much larger. A simple P-N junction solar cell is shown in fig. The generation of emf by a solar cell, When light falls on it, is due to the,

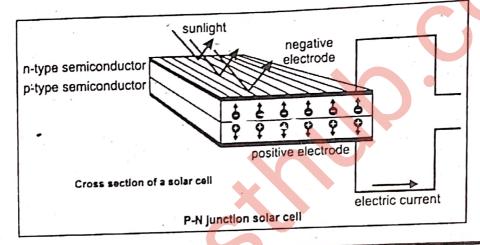
(ii) Separation of electrons and holes. (Electrons are swept to the N-side and holes to P-side) (ii) Separation of electrons and noies. (Electrons are swept to the reaching P-side are collected by the (iii) The electrons reaching the N-side are collected by the

back contact.
Thus P side becomes positive and N-side becomes negative giving rise to photo voltage. When an external load is

connected as shown in fig. a photocurrent I<sub>L</sub> flows through the load.

1) To power electronic devices in satellites and space vehicle

- 2) Solar calculators.
- 3) Solar watches



## IMPORTANT SHORT QUESTIONS FOR BOARD EXAMS

Write any two characteristics of operational amplifier.

(Fsd 2016)

High Input Resistance: Ans.

It is the resistance between (+) and (-) inputs of amplifier whose value is of the order of several mega ohms  $(2M\Omega \text{ or more})$ . So due to large value of  $R_{in}$  practically no current flows between the two input terminals.

Note: In ideal case Rin is infinite.

Low Output Resistance:

It is the resistance between output terminal and the ground. It value is only a few ohms.

It is low about  $100\Omega$ . So, op-amp can deliver practically all its output voltage to a load of  $2k\Omega$  or more connected to amplifier, which is an advantage.

Note: Ideal op-amp has zero output resistance.

Open Loop Gain:

It is the ratio of output voltage Vo to voltage difference between inverting and non-inverting inputs, when there is no external connection between the input and output.

So

$$A_{OL} = \frac{V_o}{V_+ - V_-} = \frac{V_o}{V_i}$$

The open loop gain of an amplifier is very high of the order of 10°.

What is the principle of virtual ground of operational amplifier?

(D.G.Khan 2015 Group I) (Sgd 2016 Group I)

Ans. Virtual ground:

When an op-amp is used as an inverting amplifier, input voltage is applied at inverting terminal while the noninverting terminal is grounded as shown is fig.

As open loop gain of op-amp is very high of the order or  $10^5$ . So V. ~ V, hence the input voltage (V<sub>i</sub>) is reduced to such a small value that it may be assumed to be at ground. This is called virtual ground. (Clearly, it is not the real ground)

#### What is an ideal diode?

ideal diode

ideal diode is that which offers zero resistance when it is forward biased

And offers infinite resistance when it is reverse biased.

### What is reverse or leakage current in p-n junction diode?

Leakage current

In reverse biased p-n junction, the negative terminal of the battery pulls the holes away from the junction and positive terminal attracts electrons. However, a very small current of the order of few micro amperes flows across the junction due to flow of minority charge carrier. This current is known as reverse current or leakage current in p-n junction diode.

#### What is meant by transistor? Name its three regions.

Transistor and its different regions

It is an electronic instrument which is formed by the combined effect of p-type and n-type substances, in such a way that the central substance is sandwiched its opposite substances at the other ends. It is used to amplify both current as well as voltage.

Three regions of the transistor are

- (i) Emitter
- (ii) Base
- (iii) Collector



		FORMULAE	
1	Forward resistance of pn-junction	$r_{\rm f} = \frac{\Delta V_{\rm f}}{\Delta I_{\rm f}}$	
2	Transistor current equation	$I_{E} = I_{C} + I_{B}$	
3	Current gain CE <sub>7</sub> transistor	$R = \frac{I_C}{I_B}$	
4	Gain of CE-amplifier	$A = \frac{\Delta V_o}{\Delta V_{in}}$	$A = -\beta \frac{R_C}{r_{ie}}$
5	Voltage equation for output loop	$V_{CC} = I_C R_C + V_{CE}$	~
6	Voltage equation for input loop	$V_{CC} = I_B R_B + V_{BE}$	
7	Open loop gain of an operational amplifier	$A_{OL} = \frac{V_o}{V_+ - V}$	$A_{OL} = \frac{V_o}{V_{in}}$

290
-----

	6	Gain of an inverting amplifier	$G = -\frac{R_2}{R_1}$	
	7	Gain of an non- inverting amplifier	$G = 1 + \frac{R_2}{R_1}$	
: IL	8	OR Gate	X = A + B	
IE:	10	AND Gate	X = A . B	
E	1	NOT Gate	$X = \overline{A}$	(2)
1	2	NOR Gate	$x = \overline{A + B}$	
13		JAND Gate	$x = \overline{A \cdot B}$	
		00.0-1-	$x = A\overline{B} + \overline{A}B$	
14	][^	OR Gate		
15	XI	IOR Gate	$\chi = \overline{A}\overline{B} + \overline{A}B$	

## UNITS

Γ	1	Forward or reversed resistance	ohm	Pa
1	2	Voltage gain	No unit ,	
	3	Current gain	No unit	

## CONSTANTS

1	Current gain (β)	30 – 500	Pa
2	Open loop gain of an operational	105	
Ŀ	amplifier	~ 10	

## Key Points

- Semiconductors are materials having an intermediate electric conductivity between conductors and insulators. Chemically pure semiconductors are known as intrinsic semiconductors.
- In pure semiconductors, a single event of bond breaking leads to two carriers. Namely an electron and hole. The minority carriers are generated through breaking of covalent bonds.
- The intrinsic semiconductors have low conductivity which is of little interest. But, when a small amount of impurity is added to semiconductor crystal then it greatly increases the conductivity of the intrinsic
- An N-type semiconductor is obtained by doping an intrinsic semiconductor with trivalent elements such as boron
- PN junction has special properties such as rectification.
- The net drift current through the junction is due to electron a... hole.
- The conversion of AC into DC is called the rectification and a device used for rectification is called the rotifer.
  - In transistor, there are two PN junctions, which form either PNP or NPN transistor.
- An increase in voltage or current level is called amplification. The transistor can be used as an amplifier.

## Solved Examples

#### Example 17.1:

A transistor is connected in a CE configuration. The collector supply voltage is 10V and the voltage drop across 500  $\Omega$  connected in the collector circuit is 0.6V. If  $\alpha = 0.96$ , find the (a) collector-voltage (b) base current, and (c) the emitter current.

Solution:

To collector current, 
$$I_C = \frac{V_C}{R_C} = \frac{0.6}{500}$$
  
=1.2 mA

(1) Collector-emitter voltage 
$$V_{CE} = V_{CC} - V_C = 10 - 0.6 = 9.4V$$

(2) 
$$\alpha = \frac{I_C}{I_E} \text{ or } I_E = \frac{I_C}{\alpha} = \frac{1.2}{0.96} - 1.25 \text{ mA}$$

(3) 
$$I_E = I_B + I_C$$
 or  $I_B = I_E - I_C = 1.25 - 1.2 = .05 \text{ mA}$ 

#### Example 17.2:

The constant a of a transistor is 0.95. What is would be the change in the collector current corresponding to a change of 0.4mA in the base current in a common-emitter arrangement?

#### Solution:

The current gain of transistor in common-emitter arrangement is  $\beta$ , which is related to its current-gain  $\alpha$  in

common-base arrangement 
$$\beta = \frac{\alpha}{1-\alpha}$$
 by putting values  $\beta = \frac{0.95}{1-0.95} = 19$ 

But,  $\beta$  is the ratio of change in collector current to the change in base current.

$$\beta = \frac{\Delta I_C}{\Delta I_A}$$

or 
$$\Delta I_c = \beta \times \Delta I_b = 19 \times 0.4 \times 10 - 3A = 7.6 \text{ mA}$$



## **Text Book Exercises**

- Select the correct answer of the following questions.
- In an N-type silicon, which of the following statement is true: Q.1 (a) Electrons are majority carriers and trivalent atoms are the dopants.
  - (b) Electrons are minority carriers and pentavalent atoms are the dopants
  - (c) Holes are minority carriers and pentavalent atoms are the dopants.

  - (d) Holes are majority earriers and trivalent atoms are the dopants. The reverse saturation current in a PN junction diode is only due to: (c) acceptor ions

(d) donor ions

- (b) minority carriers (ii) (a) Majority carriers Improper biasing of a transistor circuit produces:
- (iii) (a) heavy loading of emitter current
- (b) distortion in the output signal (d) faulty location of load line
- (c) excessive heat at collector terminal
- When transistors are used in digital circuit they usually operate in the: (b) breakdown region (iv)
  - (a) active region (c) saturation and cutoff regions

- (d) linear region
- Most of the electrons in the base of an NPN transistor flow: (v)
  - (b) into the collector
- (c) into the emit
- (d) into the base supply

- (a) out of the base lead In a transistor, collector current is controlled by: (vi)
  - (a) Collector voltage
- (b) base current
- (c) collector resistance
- (d) all of the above

	(a) Concer		EXPLANATION
(i)	(c)	Holes are minority carriers and pentavalent atoms are the dopants.	majority charge carriers and holes are minority charge carriers in N-type methods.
(ii)	(b)	minority carriers	Because for minority charge carrier, the battery in reverse baised state serve like a forward baised.
(iii)	(b)	distortion in the output signal	Because the path of current will not be same as we required.
(iv)	(c)	Saturation and cutoff regions	Because in digital circuit we use only two logics; logic l mean saturation and logic 0 means cut off.
(v)	(b)	into the collector	Because base region is thin and lightly dopped and also $V_{CC} >> V_{BB}$
(vi)	(b)	all of the above	As $I_C = \beta I_B$ So for a given transistor collector current is controlled by mean be base current for its normal operation.

## **Comprehensive Questions**

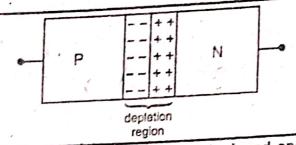
- Q.2 Write short answers of the following questions.
- Describe the energy band structure of insulator, semiconductor and conductor. 1.

Ans: See Theory Question No. 1

- 2. Explain the significance of depletion layer in an equilibrium state in a PN-junction. Give energy band diagram.
- See Theory Question No. 3 ns:

If one half of the semiconductor material dopped with trivalent impurity while the other half is dopped with pentavalent impurity. So by diffusion of electrons from N-type to P-type region, an ionic region formed. The ionic region contains positive and negative ions which are immobile charges for solids. This ionic region is called depletion region whose width depends upon impurity concentration.

Depletion region have deficiency of majority charge carriers.



2. Explain why in a transistor (a) the base is thin lightly doped and (b) the collector is larger in size.

Ans: (a) The central region of a transistor is called base which is the controlling element of a transistor. It controls the flow of charge carriers from Emitter towards the Collector. Its width is of the order of micron and it is lightly doped.

It is lightly doped so that the depletion region is thin and resistance is small. As the charge carriers will flow from emitter to the base region. So due to its small doping, very few of them will manage to recombine with charge carriers of the base region and over 99 percent charge carrier will flow towards collector to contribute into collector current.

to collector current?

(b) The main function of the collector is to collect interaction of charge carriers, the collector region region, eventually leading transistor to burn out.
So, in order to save the transistor from over healways greater than emitter and base regions.

The main function of the collector is to collect the charge carriers in the collector region. Due to interaction of charge carriers, the collector region heats up and all the heat is dissipated through this

ng and burning, the width of the collector region is

#### Explain why the base current is weak as compar

Ans. As base is the controlling element of a transistor, which is of small width and lightly doped. Due to these characteristics, the charge carrier move from Emitter to it is region, only few of them recombine with hide.

As collector-Base junction is reversed based by battery oltage V<sub>CC</sub>, which is very much greater than Emitter-Base junction battery V<sub>BB</sub> (i.e., V<sub>CC</sub>) V<sub>BB</sub>) So the voltage V<sub>CC</sub> swept layer number of charge carries from base to the collector region. Hence the collector current will increase and base current will decrease considerably.

As I IB+ lo vienes

Since I is very layer, so IB will be very small.

#### 4. Why the emitter base junction is forward based and collector base junction is reverse biased?

Ans: As transistor is the combination of two side by side PN-Junctions, one is emitter-base junction and the other is collector-base junction.

The emitter-base junction is forward baised, so the width of depletion region decreases, which will decrease the forward resistance. Hence a layer number of charge carrier will move from emitter region to the base region. The collector-base junction is reversed baised, so that this reverse voltage will be able to move the charge carriers from base region along with the charge carriers of collector regions.

### Draw the diagram of NPN and PNP transistors and explain how it works.

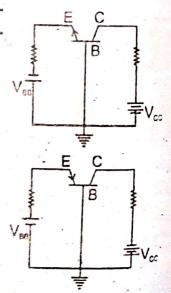
#### ins. NPN Transistor

In NPN transistor, a p-type region is sandwiched between two N-type regions. Forward baised voltage at emitter-base junction V<sub>BB</sub> will move the free electrons from emitter to base region which are swept toward collector region due to layer reverse baised voltage V<sub>CC</sub> connected at collector-base junction.

#### PNP Transistor

In PNP transistor, a N-type region is sandwiched between two P-type regions.

Forward baised voltage at emitter-base junction  $V_{BB}$  will shift the holes from emitter to base region which are swept towards collector region due to layer reverse baised voltage  $V_{CC}$  connected at collector-base junction.



	Distinguish between N (Subjective)	295
13.	Distinguish between N-type semiconductors a	and P-type semiconduct
	N-type Materials	370 Controllauctors.
	They are formed by doping of pentavalent     Pentavalent impurity.	
+	510011	2. Trivalent impurity such as boron, indium or gallium belongs to 3th group.
+	<ol> <li>In these materials, majority charge carriers are free electrons.</li> <li>In these materials</li> </ol>	3. In these materials, majority change carriers are holes.
1	4. In these materials minority charge carriers are holes.	4. In these materials minority charge carriers are free electrons.
5	Impurity atom in done and the state of the s	S Hole
L	Impurity atom is donor atom.	5. Impurity atom is acceptor atom.

#### A P-type semiconductor has a large number of holes but still it is electrically neutral. Why? 7.

First of all we know that atoms are electrically neutral because it contains equal number of electrons and the Ans: protons.

As the P-type materials are the result of doping from trivalent impurity in pure semiconductors. This will produce the ability to accept an electron which is called hole and is taken as positive. As the charge on acceptor ion is equal and opposite to the charge on hole, so the crystal will remain to neutral.

#### 8. Explain why CE configuration is widely used in amplifier circuits?

The common emitter configuration (CE) provides the maximum voltage gain as well as maximum current gain. Ans: The other configuration provide either high current gain or voltage gain but not the both. So choice of CE configuration become obvious. For this purpose emitter-base junction is forward baised so input resistance is low whereas collector-base is reversed baised so output resistance is high so the current flows from low resistance to high resistance.

#### 9. Why transistor is called current amplification device?

Transistor is basically a current amplifying device. Commonly we use common-emitter (CE) configuration for Ans: amplification.

As some external signal which is to be amplified is provided between base and emitter, it will cause to change the input voltage. So input current IB will also change. Since the current gain can be expressed as

$$\beta = \frac{\Delta I_C}{\Delta I_B}.$$

or 
$$\Delta I_C = \beta \Delta I_B$$

So it will leads the large change in collector current. It expresses that output current. Hence transistor is basically a current operating device.

10. A doped semiconductor has 10<sup>10</sup> silicon atoms and 10 trivalent atoms. If the temperature a 25°C, how many free electrons and holes are there inside the semiconductor?

Given data:

$$T = 25^{\circ}C = 298K$$
  
Total no. of atoms =  $10^{10} + 10^{1} = 1 \pm 10^{10}$ 

Solution:

As K.E = 
$$\frac{3}{2}$$
NkT  
=  $\frac{3}{2} \times 1 \times 10^{10} \times 1.38 \times 10^{-23} \times 298$   
=  $6.17 \times 10^{-11}$  J  
=  $\frac{6.17 \times 10^{-11}}{1.6 \times 10^{-19}}$  eV  
=  $3.86 \times 10^{8}$  eV

As the breakage each covelent bond results in electron-hole pair, so and energy required to break it in Si is 1.09 eV. So

No. of free electrons = no of holes = 
$$\frac{3.86 \times 10^8}{1.02}$$
  
=  $3.54 \times 10^8$ 

Where as energy required to break the covelent bond in Ge is 0.72 eV. So

No. of free electrons = no of holes = 
$$\frac{3.86 \times 10^8}{0.72}$$
  
=  $5.36 \times 10^8$ 

### Numerical Problems

In a certain circuit, the transistor has a collector current of 10 mA and a base current of 40 μA.
 What is the current gain of the transistor?

Given: Collector current  $I_c = 10 \text{mA} = 10 \times 10^{-3} \text{ A}$ 

Base current IB =  $40\mu A = 40 \times 10^{-6} A$ 

To Find:

Current gain  $\beta = ?$ 

Solution:

The current gain 'B' of transistor is

$$\beta = \frac{I_{c}}{I_{B}}$$

Putting values

$$\beta = \frac{10 \times 10^{-3} \text{ A}}{40 \times 10^{-6} \text{ A}}$$

$$\beta = 0.25 \ 0 \times 10^3 = 250$$

The current flowing into the base of a transistor is  $100 \,\mu$  A. Find its collector current  $I_c$ , its emitter current  $I_E$ , and the ratio  $I_C I_E$  if the value of current gain  $\beta$  is 100.

Given:

Base current  $I_B = 100 \mu A = 100 \times 10^{-6} A$ 

Current gain  $\beta = 100$ 

To Find:

Collector current Ic = ?

Emitter current  $I_E = ?$ 

$$\frac{IE}{IC} = ?$$

Solution:

The current gain 'B' of transistor is

$$\beta = \frac{I_C}{I_B}$$

$$I_C = \beta I_B$$

Putting values:

$$I_C = 100 \times 10^{-6} A$$

$$I_{\rm C} = 10 \times 10^{-3} \, A = 10 \, \rm mA$$

The emitter current IE is the sum of base current IB and the collector current IC.

Therefore

$$I_E = I_B + I_C$$

Putting values

$$I_E = 100 \times 10^{-6} \text{ A} + 10 \times 10^{-3} \text{ A}$$

$$IE = 10.1 \times 10^{-3} A = 10.1 \text{ mA}$$

The ratio  $\frac{I_C}{I_E}$  is

$$\frac{IC}{IE} = \frac{10 \times 10-3 \text{ A}}{10.1 \times 10-3 \text{ A}}$$

$$\frac{I_{\text{C}}}{I_{\text{E}}} = 0.99$$

3. A transistor is connected in CE configuration. The voltage drop across the load resistance ( $R_c$ ) 3 k  $\Omega$  is 6 V. Find the base current. The current gain  $\beta$  of the transistor is 0.97.

Given: Load resistance Rc =  $3k\Omega = 3 \times 10^{3} \Omega$ 

Voltage drop at load  $V_c = 6V$ 

Current gain  $\beta = 0.97$ 

To Find: Base current IB =?

Solution:

The current gain 
$$\beta$$
 of transistor is  $\beta \frac{J_c}{I_B}$  or  $I_B = \frac{I_c}{\beta} \rightarrow (i)$ 

The collector current  $I_c$  can be calculated by using Ohm's law  $I_c = \frac{V_c}{R_c}$ 

Putting values:

$$I_{\rm c} = \frac{6V}{3 \times 10^3 \Omega}$$

$$I_{\rm c} = 2 \times 10^{-3} \rm A$$

Putting values in equation (i)

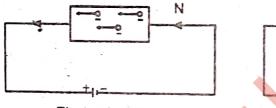
$$I_B = \frac{2 \times 10^{-3} \text{ A}}{0.97}$$

$$I_B = 2.06 \times 10^{-3} \text{ A}$$

## Additional Conceptual Short Questions With Answers

- What is difference between an elemental semiconductor and compound semiconductor?
- An elemental semiconductor consist of single species of atoms like Ge, Si. But in compound Ans. semiconductor, there are more than one element e.g. Ga As P.
- How will you distinguish between pure semiconductor and semiconductor made from metals? 2.
- The resistance of semiconductor made of Ge and Si decrease with rise in temperature. But resistance of Ans. a semiconductor made from metals increases with rise in temperature.
- How does the motion of an electron in a n-type substance differ from the motion of holes in a p. 3. type substance?
- In n-type substance, electrons are the majority charge carrier. Electron moves from lower potential (negative terminal) to a higher potential (positive terminal). The movement of these electrons is named as electronic current.

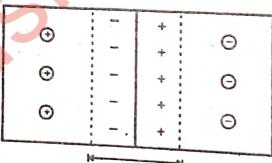
In p-type substance, holes are in majority charge carrier. Holes move from higher potential (positive potential) to a lower potential (negative potential). The movement of these holes is named at conventional current.



Electronic current

Conventional current

- What is the net charge on a n-type or a p-type substance? 4.
- There is no net charge on n-type or a p-type substance. There are electrically neutral, because thex Ans. substances contains same number of positive and negative charges.
- 5. Why charge carriers are not present in the depletion region?
- An n-region contains free electrons as majority charge carriers and p-region contains holes as majority Ans. charge carriers. Just after the formation of the junction, the diffusion of electrons and hole takes place



As a result of their diffusion, a charge less region is formed around the junction, in which charge carrier

- Which gates are knows as universal gate?
- NOR gate, NAND are called universal gate. Because by a suitable combination of NOR and NAND gate



### Self-Assessment Paper 1

	sircle the correct option.							
ONO	In p-n-p transistor, the collector current is							
-		(B) slightly less than emitter						
,	· · · · · · · · · · · · · · · · · · ·	(D) equal to base current	The second second					
	(C) greater than entitle current.  The semiconductor diode can be used as a rectifier by	ecause & bigh resistance W	hen reverse biased					
	(A) it has low resistance to the current flow when forwa (B) it has low resistance to the current flow when forwa	rd biased						
	it has high resistance to the current now when rever	Sr. Uranea						
	(D) none of these The specially designed semi conductor diodes used a	s fast counters in electronic	circuits are					
	The specialty designed senti conductor thodes used a	(B) photo diodes						
	(A) the light emitting diodes	(D) solar cells	foreign atoms whose					
	(C) photo voltaic cell	crysta it must be doped	with foreign					
	(A) the light emitting diodes (C) photo voltaic cell  To obtain an n – type semiconductor germanium	ciyati ,	(D) 5					
	Valency 2	(C) 4	(D) 5					
	(A) 2 In forward bias the width of potential barrier		(D) no effect					
	In forward bias the width of potential out for	(C) remains same	(D) no chief					
	(A) increases In a transistor, collector current is controlled by:		(D) none of these					
	In a transistor, conector current is controlled by	(C) collector	(D) hone of					
	(A) Emitter (B) base The thickness of base is a transistor is of the order of	of.	(D) $10^{-6} mm$					
	The thickness of base is a transform (B) $10^{-9}m$	(C) $10^{-6} m$	(D) 10 mm					
	(A) $10^{-3}m$ (B) $10^{-9}m$	nductors.	(D) Gallium arsenide					
	(A) 10 m  Light emitting diodes (LED) are made from semicor  (B) Germanium	(C) Carbon	(D) Gaintin assert					
	(A) Silicon (B) Germanium  The reverse saturation current in Pn junction is the	result of flow of:	(D) donor ions					
	The reverse saturation current in Full June 10 to 10 majority carriers (B) minority carriers	(C) acceptor ions	(D) dollor tons					
	(A) majority carriers (B) minority carriers		_					
	The current gain $\beta$ of a transistor is:		(D) $\frac{I_B}{I_C}$					
	(A) $\frac{I_C}{I_B}$	$(C)\frac{I_c}{I}$	$\frac{(D)}{I_c}$					
	(A) $\frac{I_C}{I}$ (B) $\frac{I_E}{I_B}$	$I_{E}$						
No.2 Write Short Answers any SIX of the following questions.								
No.	Write Short Answers any 31x of the							
	What is the principle of virtual ground?	on.						
	a the formation of depletion region							
	What are the applications of photo dis-							
	What are the applications of photos where the applications of photos where ? What is the net charge on n and p-type substance? The inputs of a gate are 1 and 0, identify the gate if its transistor is very small?	output is (a) 0 (b) 1.						
		Output ( )						
	The inputs of a gate are Tand 0, techniques Why the base current in a transistor is very small? What are biasing and switching terminal of a common	emitter transistor for work	ng its a switch?					
	What are hissing and switching terminal of a common	CHICCI						
	AALIGI GIC DIGGILD							

- (a) What is amplification? Derive the expression for the gain of common emitter amplifier. No.3Extensive Question.
- (b) In a certain circuit, the transistor has a collector current of 10 mA and a base current of 40 micro ampere. What is the current gain of the transistor?

## Self-Assessment Paper 2

Q	No.	1 Encircle the correct option.					
1.	1	The colour of light emitted by LED depends on  (A) its forward biasing  (C) the amount of forward current	(B) the type of semi conductor material used (D) its reverse biasing				
2.		The energy gap for Germanium at 0K is. (A) 1.12 eV (B) 0.02 eV	(C) 6.72 eV	(D) 7.2 eV			
3.	,	In reverse bias the width of potential barrier (A) increases (B) decreases	(C) remains same	(D) no effect			
4.		To obtain an n - type semiconductor germanium valency is		A Comment			
5.		(A) 2 (B) 3 Light emitting diodes (LED) are made from semicol		(D) 5			
6.		(A) Silicon (B) Germanium A pn junction cannot be used as:	(C) Carbon	(D) Gallium arsenide			
7.	· · · · · · · · · · · · · · · · · · ·	(A) A detector (B) A rectifier  The minimum number of semi conductor diodes rec	(C) An amplifier quired for full wave rectifications	(D) A counter			
8.	,	(A) 1 (B) 2 The gain of non inverting OP – Amp of external res	(C) 3	(D) 4			
9.		(A) 0.1 (B) 10 A sensor of light is	(C) 11	(D) – 10			
,		(A) transistor (C) light dependent resistance	(B) LED (D) semi conductor diode				
Q.	No.	Write Short Answers any SIX of the following					
1. 2. 3.		What is a logic gate? Explain. Why ordinary silicon lig Why base current in transistor is very small?	tht does not emit light?				
4. 5.		Why transistor is called current amplification device? Why photodiode is operated in reverse biased state? What are forward and reverse biased state?					
6.		What are forward and reverse biasing of PN junction diode? What are the biasing requirements of the junctions of a transistor for its normal operation? Explain how these requirements are met in a common emitter amplifier?					
7.		Why NAND and NOR gates are called universal gates?					
Telepit.	THE RES	3Extensive Questions.					
Q.	(a) (b)	Define rectification. Explain half-wave rectifier.  A transistor is connected in CE configuration, The vol the base curren. The current gain of the transistor is 0.9	ltage drop across load resistar	nce is 3 kilo ohm is 6V. Find			

 $\bigcirc \bigcirc \bigcirc \bigcirc \bigcirc \bigcirc \bigcirc \bigcirc \bigcirc \bigcirc$